

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Divisional Application of Serial No. )  
09/812,688, filed March 21, 2001, of: )  
Masamitsu ITOH et al. ) Group Art Unit: To be Assigned  
Application No.: To be Assigned ) Examiner: To be Assigned  
Filed: Herewith )  
For: PATTERN FORMATION )  
MATERIAL, PATTERN )  
FORMATION METHOD, AND )  
EXPOSURE MASK )  
FABRICATION METHOD )

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**PRELIMINARY AMENDMENT**

Prior to the examination of the above application, please amend this application  
as follows:

**Amendments to the Specification** begins on page 2.

**Amendments to the Claims** are reflected in the listing of claims beginning on  
page 3.

**Remarks** follow the amendment sections of this paper.